

**ELECTRONIC COPY** 

LABORATORY GROWN DIAMOND REPORT

## LABORATORY GROWN DIAMOND REPORT

LG607308619 Report verification at igi.org

#### LABORATORY GROWN DIAMOND REPORT

## **GRADING SCALES**

## CLARITY

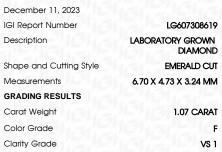
IF	VVS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	l <sup>1-3</sup>
Internally	Very Very	Very	Slightly	Included
Flawless	Slightly Included	Slightly Included	Included	

## COLOR

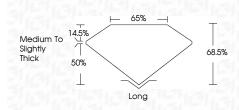
D E F G H I J Faint Very Light	) E	D	EFGH	H I J	Faint Very Light	Light
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1691 LG607308619

Sample Image Used



LABORATORY GROWN DIAMOND REPORT



#### ADDITIONAL GRADING INFORMATION

Polish	VERY GOOD
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	(67) LG607308619
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa	



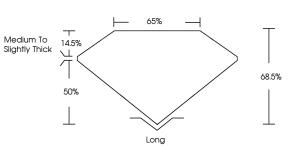
	DIANO
Shape and Cutting Style	EMERALD C
Measurements	6.70 X 4.73 X 3.24 M
GRADING RESULTS	
Carat Weight	1.07 CAR
Color Grade	
Clarity Grade	v

### **KEY TO SYMBOLS**

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

PROPORTIONS

**CLARITY CHARACTERISTICS** 



# **GRADING RESULTS**

Shape and Cutting Style

December 11, 2023

IGI Report Number

Description

Measurements

Carat Weight	1.07 CARAT
Color Grade	F
Clarity Grade	VS 1

LG607308619

DIAMOND

**EMERALD CUT** 

LABORATORY GROWN

6.70 X 4.73 X 3.24 MM

## ADDITIONAL GRADING INFORMATION

Polish	VERY GOOD
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	131 LG607308619

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa

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